

CERTIFICATE OF MAILING BY FIRST CLASS MAIL (37 CFR 1.8)

Applicant(s): Yasushi AKIYAMA et al.

Docket No.

2002JP311

Serial No.

10/519,242

Filing Date

December 22, 2004

Examiner

WU, Ives J.

Group Art Unit

1713

Invention: **COMPOSITION FOR ANTIREFLECTIVE COATING AND METHOD FOR FORMING SAME**

SEP 16 2005

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Maria T. Sanchez
(Signature of Person Mailing Correspondence)

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PATENT ABSTRACTS OF JAPAN

(11)Publication number : 08-305032

(43)Date of publication of application : 22.11.1996

(51)Int.Cl. G03F 7/11

H01L 21/027

(21)Application number : 07-131096 (71)Applicant : HOECHST IND KK

(22)Date of filing : 01.05.1995 (72)Inventor : IWATA YUTAKA

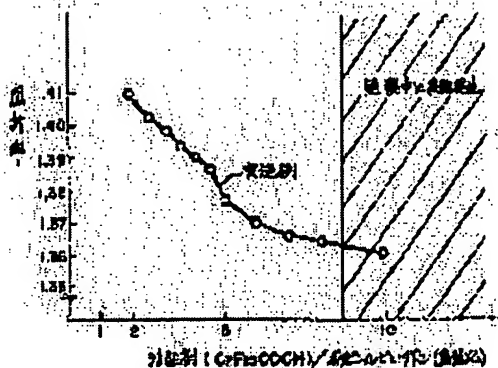
YOSHIDA TAKEO

(54) COMPOSITION FOR ANTIREFLECTION COATING

(57)Abstract:

PURPOSE: To obtain a compsn. for forming a high quality anti-interference film on a photoresist film by incorporating perfluoro alkylcarboxylic acid, org. amine, polyvinylpyrrolidone and water.

CONSTITUTION: This compsn. contains perfluoroalkylcarboxylic acid, org. amine, polyvinylpyrrolidone and water. The perfluoroalkylcarboxylic acid is a compd. represented by the formula $C_nF_{2n+1}COOH$ [where (n) is 5-10] and $C_7F_{15}COOH$ is preferably used. The perfluoroalkylcarboxylic acid is used as an activator and dissolves under coexistence of a basic substance. The basic substance used here is the org. amine and alkanolamine, especially monoethanolamine is preferably used. By the combination of the components, a lower refractive index is ensured and a slightly soluble layer is not formed on a resist.



LEGAL STATUS [Date of request for examination] 27.02.2002

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number] 3510003

[Date of registration] 09.01.2004

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]

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